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APPLICATION NO.	FILING DATE	. FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/692,661	10/24/2003	. Wiltold Paw	49022/59150 US	9926
21874	7590 06/28/2005		EXAMINER	
EDWARDS & ANGELL, LLP			VINH, LAN	
P.O. BOX 55 BOSTON, N	· · ·		ART UNIT PAPER NUMBER	
			1765	
			DATE MAILED: 06/28/200	5

Please find below and/or attached an Office communication concerning this application or proceeding.

			11 / 10			
	Application No.	Applicant(s)				
	10/692,661	PAW ET AL.				
Office Action Summary	Examiner	Art Unit				
	Lan Vinh	1765				
The MAILING DATE of this communication Period for Reply	n appears on the cover sheet	with the correspondence addres	ss			
A SHORTENED STATUTORY PERIOD FOR RITHE MAILING DATE OF THIS COMMUNICATION - Extensions of time may be available under the provisions of 37 Cf after SIX (6) MONTHS from the mailing date of this communication - If the period for reply specified above is less than thirty (30) days, - If NO period for reply is specified above, the maximum statutory properties of the period for reply within the set or extended period for reply will, by any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).	ON. FR 1.136(a). In no event, however, may a son. a reply within the statutory minimum of the statutory will expire SIX (6) MC statute, cause the application to become a	reply be timely filed irty (30) days will be considered timely. NTHS from the mailing date of this commu. ABANDONED (35 U.S.C. § 133).	unication.			
Status			:			
1) Responsive to communication(s) filed on	24 October 2003.					
	This action is non-final.					
3) Since this application is in condition for all closed in accordance with the practice und	owance except for formal ma		erits is			
Disposition of Claims	•	1				
 4) ☐ Claim(s) 1-10 is/are pending in the application 4a) Of the above claim(s) is/are with 5) ☐ Claim(s) is/are allowed. 6) ☐ Claim(s) 1-3 and 5-9 is/are rejected. 7) ☐ Claim(s) 4, 10 is/are objected to. 8) ☐ Claim(s) are subject to restriction and continuous pending in the application and continuous pending in	ndrawn from consideration.		·			
Application Papers						
9)☐ The specification is objected to by the Exa	miner					
o)☐ The drawing(s) filed on is/are: a)☐ accepted or b)☐ objected to by the Examiner.						
Applicant may not request that any objection to		=				
Replacement drawing sheet(s) including the co	prection is required if the drawin	g(s) is objected to. See 37 CFR 1	.121(d).			
11)☐ The oath or declaration is objected to by th	e Examiner. Note the attache	ed Office Action or form PTO-1	52.			
Priority under 35 U.S.C. § 119						
12) Acknowledgment is made of a claim for for a) All b) Some * c) None of: 1. Certified copies of the priority docum 2. Certified copies of the priority docum 3. Copies of the certified copies of the application from the International But * See the attached detailed Office action for a	nents have been received. nents have been received in priority documents have bee ureau (PCT Rule 17.2(a)).	Application No n received in this National Sta	ge :			
Attachment(s)						
Notice of References Cited (PTO-892)		Summary (PTO-413)				
 Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SE Paper No(s)/Mail Date 		(s)/Mail Date Informal Patent Application (PTO-152)			

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 2. Claims 1, 5 are rejected under 35 U.S.C. 102(b) as being anticipated by llardi et al (US 5,466,389)

llardi discloses a method for cleaning microelectronic substrate. The method comprises the steps of:

supplying a substrate fabricated substantially of silicon (col 5, lines 48-50)

exposing the substrate to an alkaline cleaner solution (col 3, lines 56-60), which reads on exposing the substrate to an etching bath containing a caustic etching solution the cleaner solution contains additives such as chlorite salt, an iodate salt (col 4, lines 21-28)

Regarding claim 5, llardi discloses that the alkaline cleaner comprises 0.1-10 % of addictive (col 13, lines 10-13), which reads on wherein the additive has an additive concentration of at least about 0.01% by weight.

Claim Rejections - 35 USC § 103

3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

Application/Control Number: 10/692,661

Art Unit: 1765

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

4. Claims 2-3, 6-8 are rejected under 35 U.S.C. 103(a) as being unpatentable over llardi et al (US 5,466,389) in view of Maeno et al (US 5,714,407)

llardi method has been described above. Unlike the instant claimed inventions as per claims 2-3, llardi fails to disclose using additives such as potassium iodate or sodium iodate in the cleaner solution

Maeno discloses a method for manufacturing an electronic device using an etching agent comprises the step of using additives such as potassium iodate or sodium iodate in the etching solution (col. 5, lines 2-7)

Since llardi discloses that the cleaner solution contains additive such as an iodate salt, one skilled in the art at the time the invention was made would have found it obvious to modify llardi's cleaner solution by adding additives such as potassium iodate or sodium iodate in view of Maeno because Maeno discloses potassium iodate is easiest to handle and thus preferable (col 5, lines 5-8)

Unlike the instant claimed inventions as per claims 6-8, llardi fails to disclose forming the additive by chemical reaction between iodic acid and hydroxide/I2 with chlorate in the etching bath

Maeno also discloses forming the additive by chemical reaction of the iodic acid in the etching solution (col 5, lines 9-12)

One skilled in the art at the time the invention was made would have found it obvious to modify llardi method by using iodic acid in the cleaner solution because Maeno

Application/Control Number: 10/692,661

Art Unit: 1765

discloses that the etching agent preferably contains iodine ions because the addition of iodine ions changes iodine generated by the etching into I_3 - which dissolves the agent, thereby preventing the precipitation of halogen or the like, thus it is possible to prevent etching defects (col 5, lines 15-19)

5. Claim 9 is rejected under 35 U.S.C. 103(a) as being unpatentable over llardi et al (US 5,466,389) in view of Morita et al (US 6,431,186)

llardi method has been described above. Unlike the instant claimed invention as per claim 9, llardi fails to disclose using additives such as sodium chlorite

Morita discloses a method for cleaning electronic component using a cleaning solution contains additive such as sodium chlorite (col 3, lines 15-17)

Since llardi cleaner solution is an alkaline solution, one skilled in the art at the time the invention was made would have found it obvious to modify llardi's cleaner solution by using additive such as sodium chlorite as per Morita because according to Morita, fluids contains oxidizing substance such as sodium chlorite supplemented with an alkaline solution can be used (col 3, lines 12-33)

Allowable Subject Matter

6. Claims 4, 10 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Conclusion

7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Lan Vinh whose telephone number is 571 272 1471. The examiner can normally be reached on M-F 8:30-5:30 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on 571 272 1465. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

June 23, 2004